

Gallium Nitride E-Mode HEMT

GS700EWF165G1: 165mΩ, 700V



Description

This is a 700V GaN-on-Si enhancement-mode power transistor in Wafer. The properties of GaN allow for high current, high breakdown voltage and high switching frequency.

Features

- Ultra-low FOM
- Ultra-high switching frequency
- Reverse current capability
- Zero reverse recovery loss
- Monolithic integrated ESD protection
- RoHS, Pb-free, REACH-compliant

Applications

- AC/DC converters
- DC/DC converters
- Bridgeless totem pole PFC
- Fast chargers
- Power adapters
- LED lighting drivers
- Wireless power transfer
- Laser drivers
- TV display

Table 1 Key Performance Parameters at T_j = 25 °C

Parameters	Values	Units
V _{DS, max}	700	V
R _{DS(on), max}	240	mΩ
Q _G	2.5	nC
I _{D, Pulse}	18	A
Q _{OSS @ 400 V}	17	nC

Table 2 Order Information

Ordering Code	MOQ
GS700EWF165G1	12pcs wafers

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1 Maximum ratings

at $T_j = 25\text{ }^{\circ}\text{C}$ unless otherwise specified. Continuous application of maximum ratings can deteriorate transistor lifetime.

Table 3 Maximum rating

Parameters	Symbols	Values	Units	Notes/Test Conditions
Drain-source voltage	$V_{DS, \max}$	700	V	$V_{GS} = 0\text{ V}$ $T_j = -55\text{ }^{\circ}\text{C}$ to $150\text{ }^{\circ}\text{C}$
Drain-source voltage transient ¹	$V_{DS, \text{transient}}$	800	V	$V_{GS} = 0\text{ V}$
Continuous current, drain-source	I_D	10	A	$T_c = 25\text{ }^{\circ}\text{C}$
Pulsed current, drain-source ²	$I_{D, \text{pulse}}$	18	A	$T_c = 25\text{ }^{\circ}\text{C}$; $V_G = 6\text{ V}$
Pulsed current, drain-source ²	$I_{D, \text{pulse}}$	10	A	$T_c = 125\text{ }^{\circ}\text{C}$; $V_G = 6\text{ V}$
Gate-source voltage, continuous	V_{GS}	-1 to +6	V	$T_j = -55\text{ }^{\circ}\text{C}$ to $150\text{ }^{\circ}\text{C}$
Gate-source voltage, pulsed	$V_{GS, \text{pulse}}$	-20 to +10	V	$T_j = -55\text{ }^{\circ}\text{C}$ to $150\text{ }^{\circ}\text{C}$; $t_{\text{Pulse}} = 50\text{ ns}$, $f = 100\text{ kHz}$; open drain
Power dissipation	P_{tot}	75	W	$T_c = 25\text{ }^{\circ}\text{C}$
Operating temperature	T_j	-55 to +150	$^{\circ}\text{C}$	
Storage temperature	T_{stg}	-55 to +150	$^{\circ}\text{C}$	

1. $V_{DS, \text{transient}}$ is intended for surge rating during non-repetitive events, $t_{\text{Pulse}} < 1\text{ }\mu\text{s}$.

2. Pulse width = 10 μs .

2 Thermal characteristics

Table 4 Thermal characteristics

Parameters	Symbols	Values			Units	Notes/Test Conditions
		Min.	Typ.	Max.		
Thermal resistance, junction-ambient	R_{thJA}		80		$^{\circ}\text{C/W}$	
Thermal resistance, junction-case	R_{thJC}	-	1.65	-	$^{\circ}\text{C/W}$	
Reflow soldering temperature	T_{sold}	-	-	260	$^{\circ}\text{C}$	MSL3

3 Electrical characteristics

at $T_j = 25\text{ }^{\circ}\text{C}$, unless specified otherwise.

Table 5 Static characteristics

Parameters	Symbols	Values			Units	Notes/Test Conditions
		Min.	Typ.	Max.		
Gate threshold voltage	$V_{GS(TH)}$	1.0	1.6	2.5	V	$I_D = 9\text{ mA}$; $V_{DS} = V_{GS}$; $T_j = 25\text{ }^{\circ}\text{C}$
		-	2	-		$I_D = 9\text{ mA}$; $V_{DS} = V_{GS}$; $T_j = 150\text{ }^{\circ}\text{C}$
Drain-source leakage current	I_{DSS}	-	0.01	0.9	μA	$V_{DS} = 700\text{ V}$; $V_{GS} = 0\text{ V}$; $T_j = 25\text{ }^{\circ}\text{C}$
		-	1	-		$V_{DS} = 700\text{ V}$; $V_{GS} = 0\text{ V}$; $T_j = 150\text{ }^{\circ}\text{C}$
Gate-source leakage current	I_{GSS}	-	2		μA	$V_{GS} = 6\text{ V}$; $V_{DS} = 0\text{ V}$
Drain-source on-state resistance	$R_{DS(on)}$	-	165	240	$\text{m}\Omega$	$V_{GS} = 6\text{ V}$; $I_D = 3\text{ A}$; $T_j = 25\text{ }^{\circ}\text{C}$
		-	390	-	$\text{m}\Omega$	$V_{GS} = 6\text{ V}$; $I_D = 3\text{ A}$; $T_j = 150\text{ }^{\circ}\text{C}$
Gate resistance	R_G	-	6.5	-	Ω	$f = 5\text{ MHz}$; open drain

Table 6 Dynamic characteristics

Parameters	Symbols	Values			Units	Notes/Test Conditions
		Min.	Typ.	Max.		
Input capacitance	C_{iss}	-	65	-	pF	$V_{GS} = 0\text{ V}$; $V_{DS} = 400\text{ V}$; $f = 100\text{ KHz}$
Output capacitance	C_{oss}	-	20.6	-	pF	$V_{GS} = 0\text{ V}$; $V_{DS} = 400\text{ V}$; $f = 100\text{ KHz}$
Reverse transfer capacitance	C_{rss}	-	0.14	-	pF	$V_{GS} = 0\text{ V}$; $V_{DS} = 400\text{ V}$; $f = 100\text{ KHz}$
Effective output capacitance, energy related ¹	$C_{o(er)}$	-	30	-	pF	$V_{GS} = 0\text{ V}$; $V_{DS} = 0\text{ to }400\text{ V}$
Effective output capacitance, time related ²	$C_{o(tr)}$	-	48	-	pF	$V_{GS} = 0\text{ V}$; $V_{DS} = 0\text{ to }400\text{ V}$
Output charge	Q_{oss}	-	17	-	nC	$V_{GS} = 0\text{ V}$; $V_{DS} = 0\text{ to }400\text{ V}$
Turn-on delay time	$t_{d(on)}$	-	2	-	ns	$V_{DS} = 400\text{ V}$; $I_D = 6\text{ A}$; $L = 318\text{ }\mu\text{H}$; $V_{GS} = 6\text{ V}$; $R_{on} = 10\text{ }\Omega$; $R_{off} = 2\text{ }\Omega$
Turn-off delay time	$t_{d(off)}$	-	3	-	ns	
Rise time	t_r	-	4	-	ns	
Fall time	t_f	-	5	-	ns	

1. $C_{o(er)}$ is the fixed capacitance that gives the same stored energy as C_{oss} while V_{DS} is rising from 0 to 400 V.
2. $C_{o(tr)}$ is the fixed capacitance that gives the same charging time as C_{oss} while V_{DS} is rising from 0 to 400 V.

Table 7 Gate charge characteristics

Parameters	Symbols	Values			Units	Notes/Test Conditions
		Min.	Typ.	Max.		
Gate charge	Q_G	-	2.0	-	nC	$V_{GS} = 0 \text{ to } 6 \text{ V}; V_{DS} = 400 \text{ V};$ $I_D = 3 \text{ A}$
Gate-source charge	Q_{GS}	-	0.4	-	nC	
Gate-drain charge	Q_{GD}	-	0.7	-	nC	
Gate plateau voltage	V_{plat}	-	2.5	-	V	$V_{DS} = 400 \text{ V}; I_D = 3 \text{ A}$

Table 8 Reverse conduction characteristics

Parameters	Symbols	Values			Units	Notes/Test Conditions
		Min.	Typ.	Max.		
Source-drain reverse voltage	V_{SD}	-	4.0	-	V	$V_{GS} = 0 \text{ V}; I_{SD} = 3 \text{ A}$
Pulsed current, reverse	$I_{S, \text{pulse}}$	-	-	18	A	$V_{GS} = 6 \text{ V}$
Reverse recovery charge ¹	Q_{rr}	-	0	-	nC	$I_{SD} = 3 \text{ A}; V_{DS} = 400 \text{ V}$
Reverse recovery time	t_{rr}	-	0	-	ns	
Peak reverse recovery current	I_{rm}	-	0	-	A	

1. Excluding Q_{oss}

4 Electrical characteristics diagrams

at $T_j = 25\text{ }^{\circ}\text{C}$, unless specified otherwise.

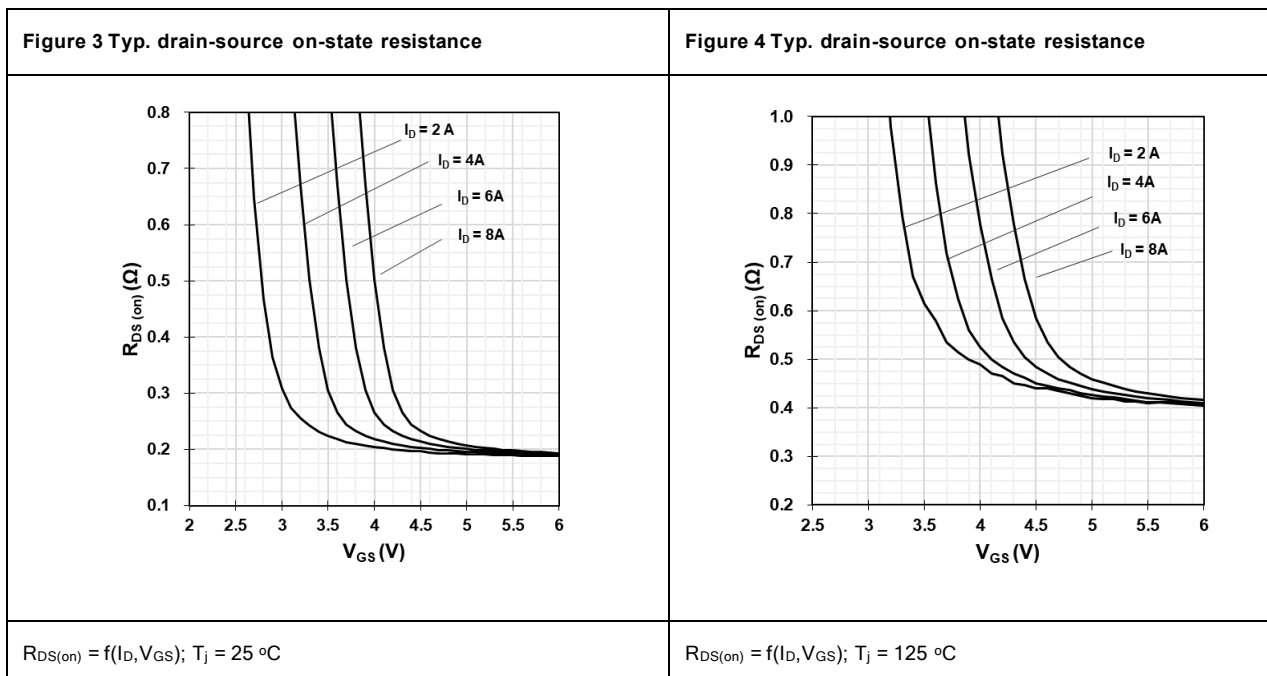
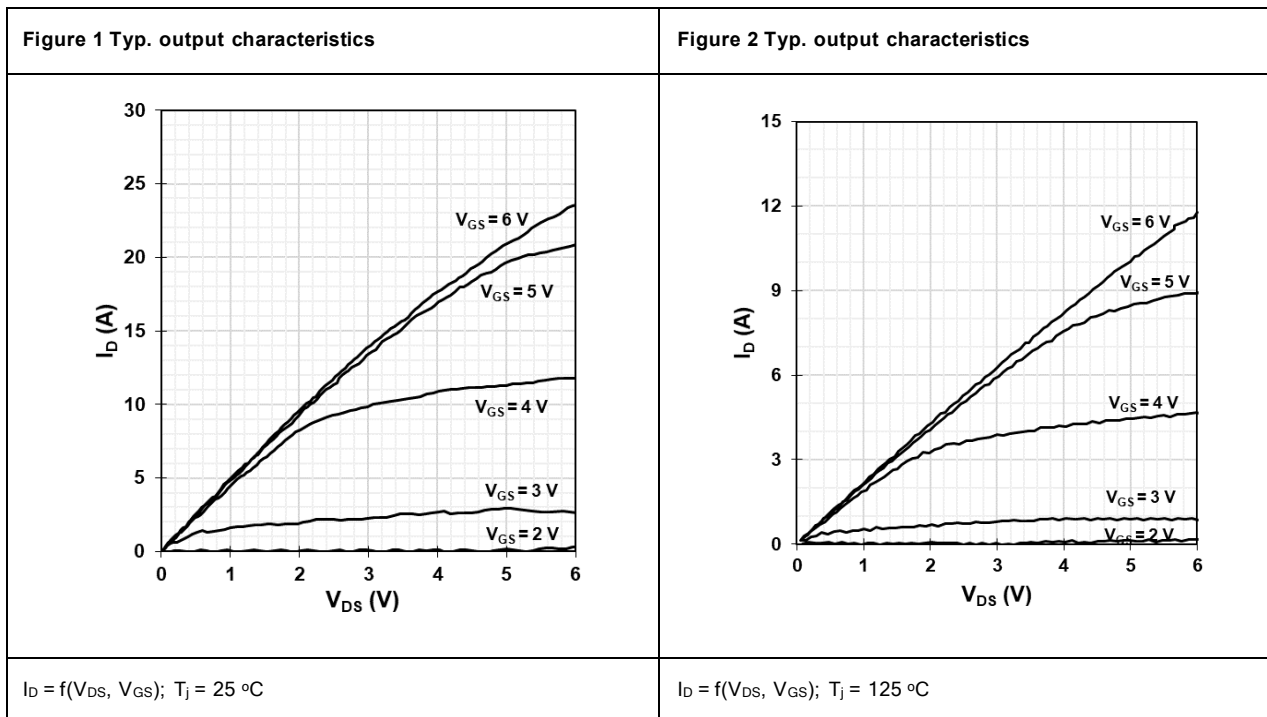


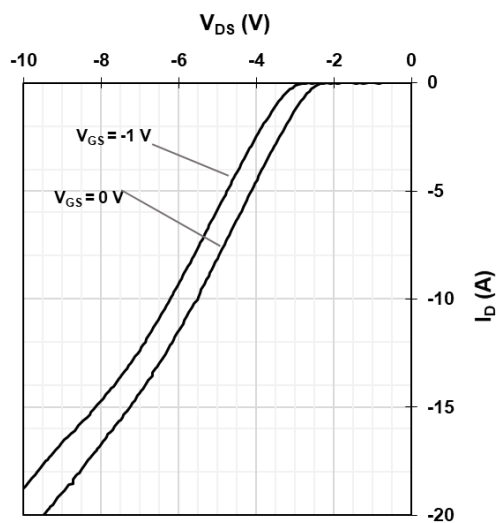
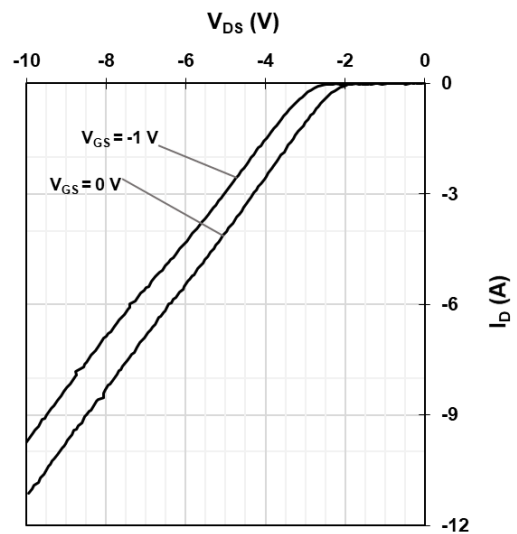
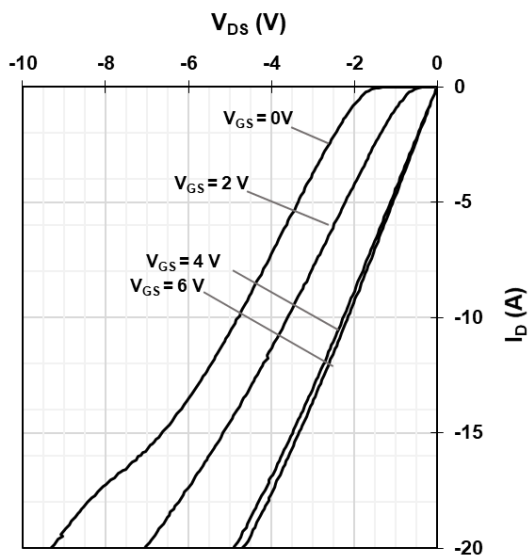
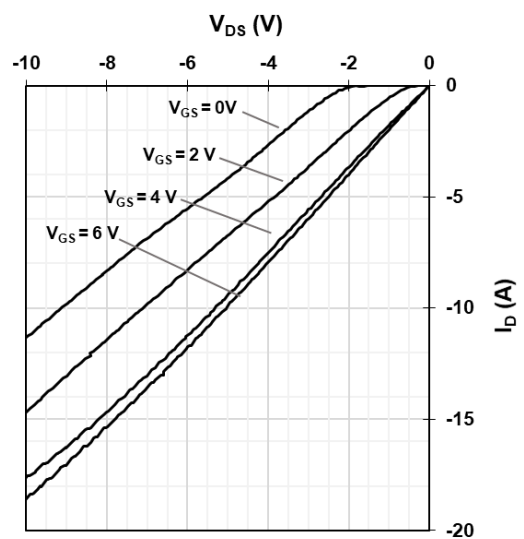
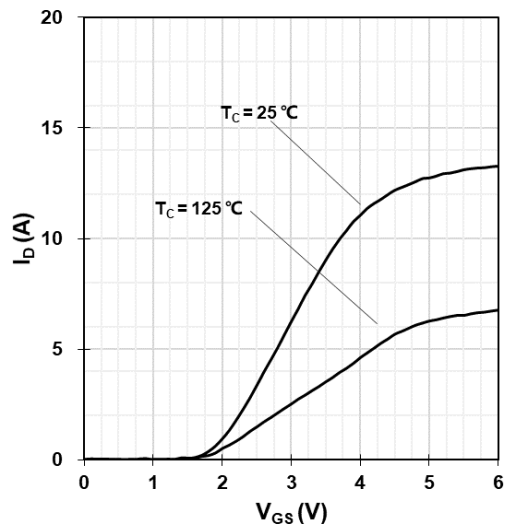
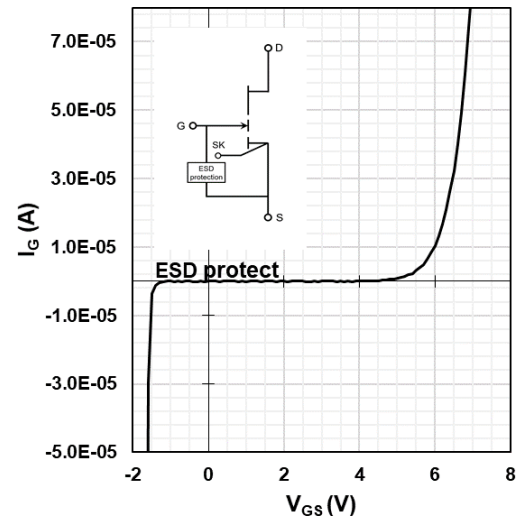
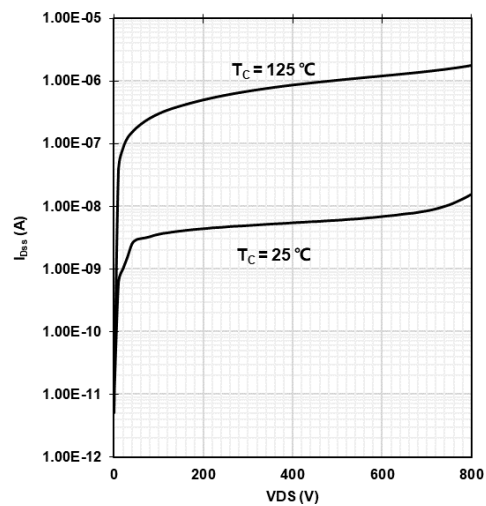
Figure 5 Typ. channel reverse characteristics

 $I_D = f(V_{DS}, V_{GS}); T_j = 25\text{ }^{\circ}\text{C}$
Figure 6 Typ. channel reverse characteristics

 $I_D = f(V_{DS}, V_{GS}); T_j = 125\text{ }^{\circ}\text{C}$
Figure 7 Typ. channel reverse characteristics

 $I_D = f(V_{DS}, V_{GS}); T_j = 25\text{ }^{\circ}\text{C}$
Figure 8 Typ. channel reverse characteristics

 $I_D = f(V_{DS}, V_{GS}); T_j = 125\text{ }^{\circ}\text{C}$

Figure 9 Typ. transfer characteristics


$$I_D = f(V_{GS}); V_{DS} = 3\text{ V}$$

Figure 10 Typ. gate-to-source leakage


$$I_G = f(V_{GS}); V_D = \text{open}$$

Figure 11 Drain-source leakage characteristics


$$I_{DSS} = f(V_{DS}); V_{GS} = 0\text{ V}$$

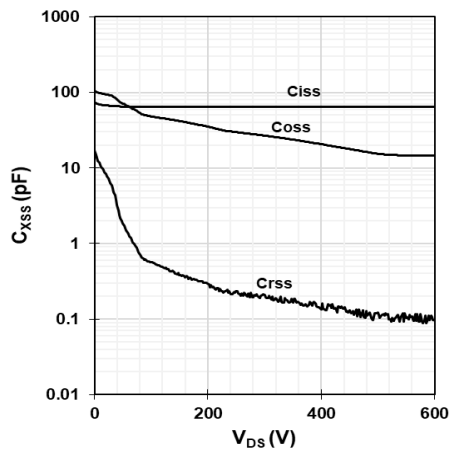
Figure 12 Typ. capacitances

 $C_{XSS} = f(V_{DS})$; Freq. = 100kHz

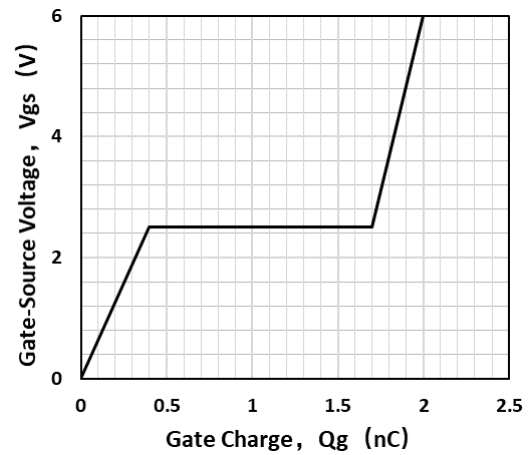
Figure 13 Typ. gate charge

 $V_{GS} = f(Q_g)$; $V_{DS} = 400$ V; $I_D = 3$ A

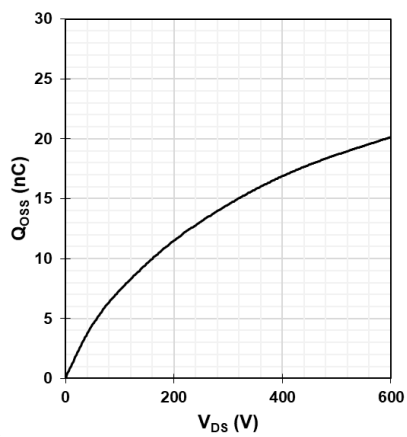
Figure 14 Typ. output charge

 $Q_{OSS} = f(V_{DS})$; Freq. = 100kHz

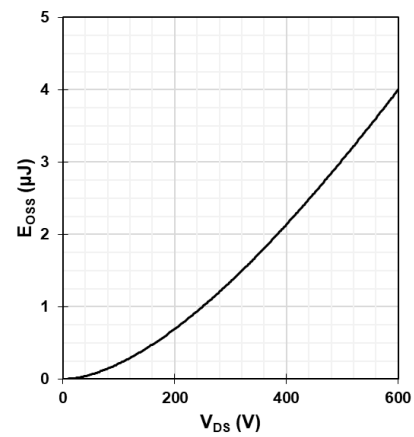
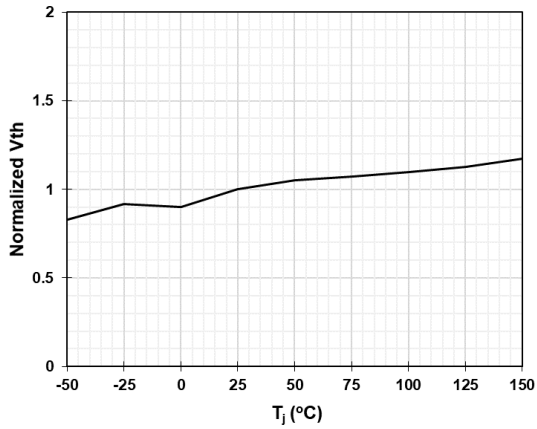
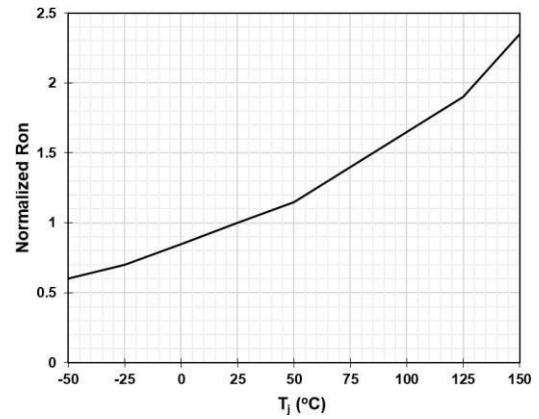
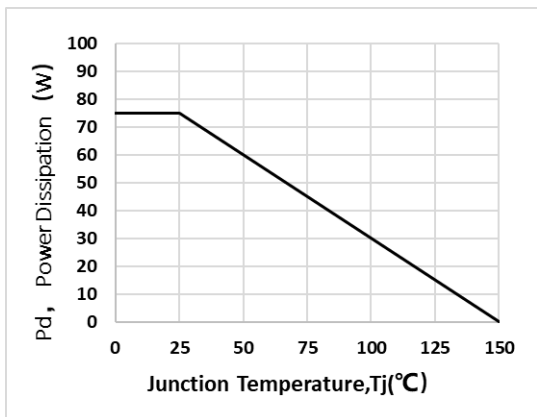
Figure 15 Typ. C_oss stored energy

 $E_{OSS} = f(V_{DS})$; Freq. = 100kHz

Figure 16 Gate threshold voltage


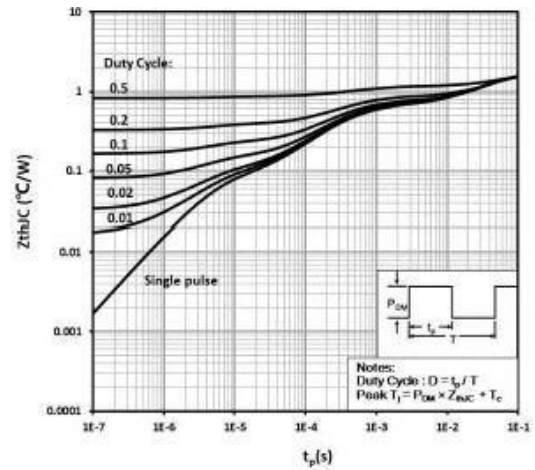
$$V_{GS(TH)} = f(T_j); V_{GS} = V_{DS}; I_D = 16 \text{ mA}$$

Figure 17 Drain-source on-state resistance


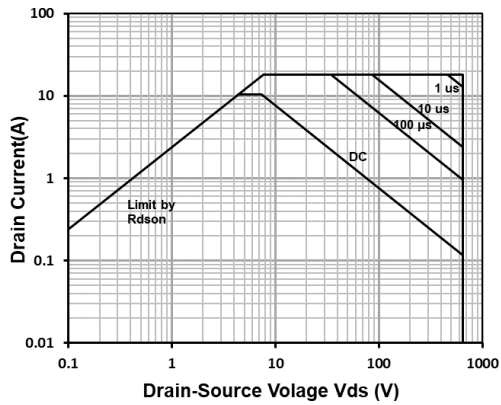
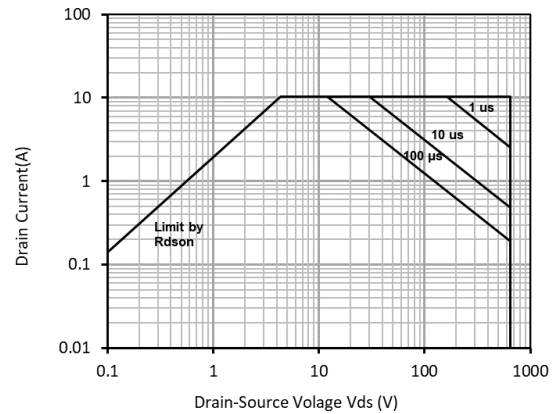
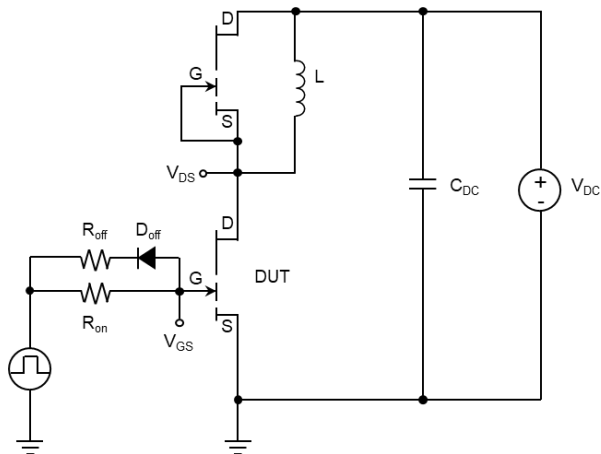
$$R_{DS(on)} = f(T_j); I_D = 5 \text{ A}; V_{GS} = 6 \text{ V}$$

Figure 18 Power dissipation


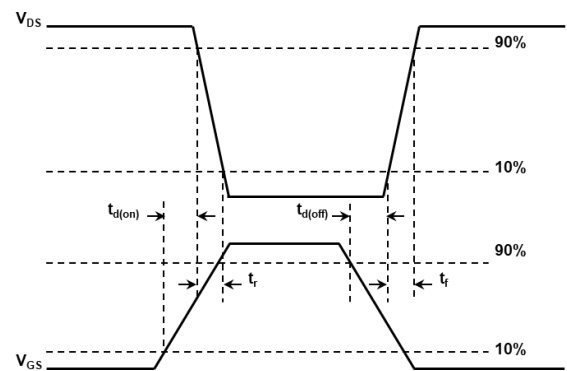
$$P_{tot} = f(T_c)$$

Figure 19 Max.transient thermal impedance


$$Z_{thjc} = f(tp, D)$$

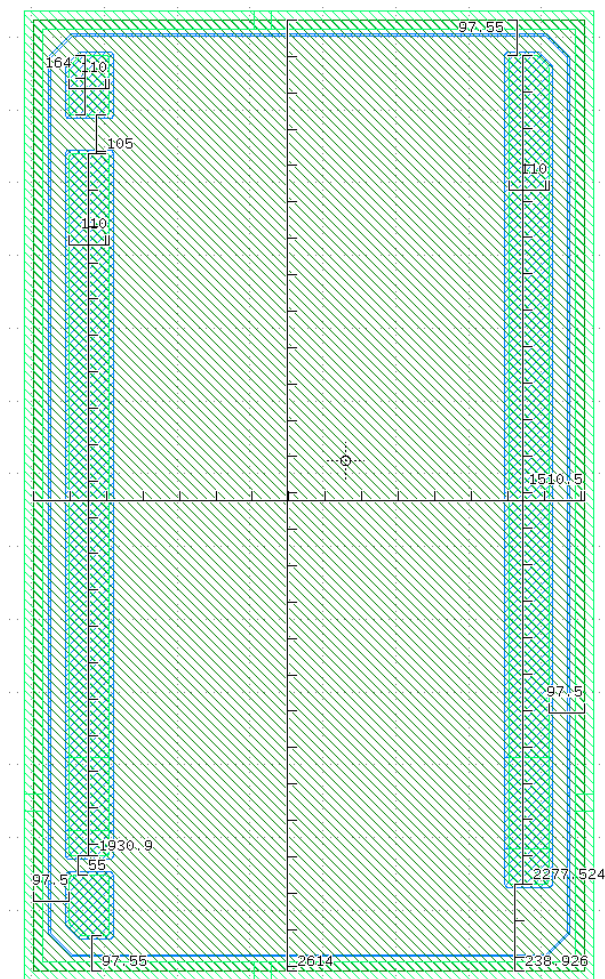
Figure 20 Safe Operation Area

 $I_d = f(V_{ds}); T_c = 25^\circ\text{C}$
Figure 21 Safe Operation Area

 $I_d = f(V_{ds}); T_c = 125^\circ\text{C}$
Figure 22 Switching time test circuit


$V_{DS} = 400\text{ V}, I_D = 6\text{ A}, L = 318\text{ }\mu\text{H}, V_{GS} = 6\text{ V},$
 $R_{on} = 10\text{ }\Omega, R_{off} = 2\text{ }\Omega$

Figure 23 Typ. switching time waveforms


5 Die Information

Parameter	Parameter
Wafer Size	6inch
Die size (With SL)	2614um*1510.5um
Gate Pad Size	164um*110um
Source Pad Size	1930.9um*110um
Drain Pad Size	2277.5um*110um
Scribe Line Size (PI CD)	50um
Top metal	4um, AlCu
Chip surface	3 um SiO ₂ + 0.5um SiN+10um PI
Recommended dicing method	Direct cutting without laser grooving



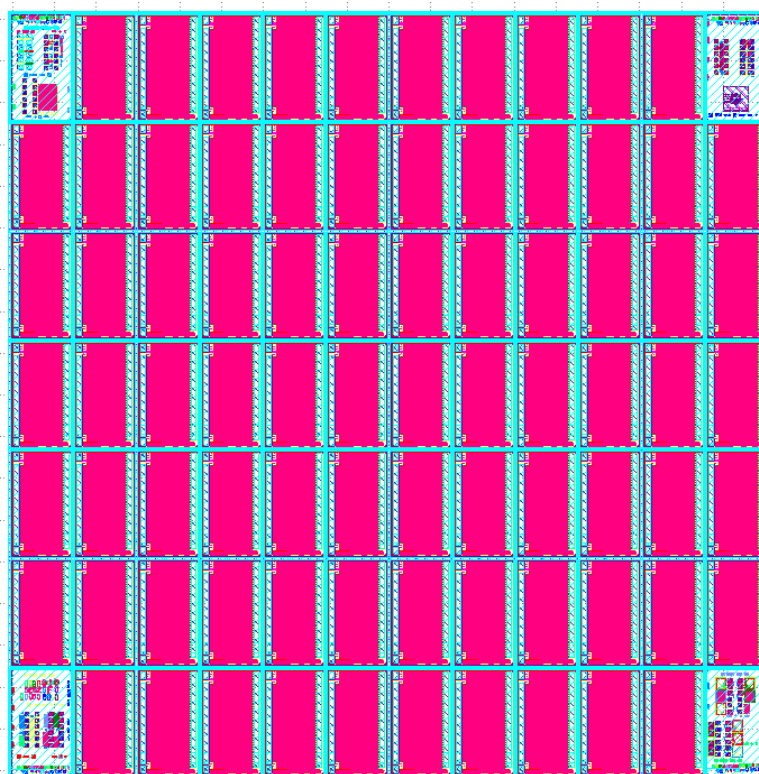
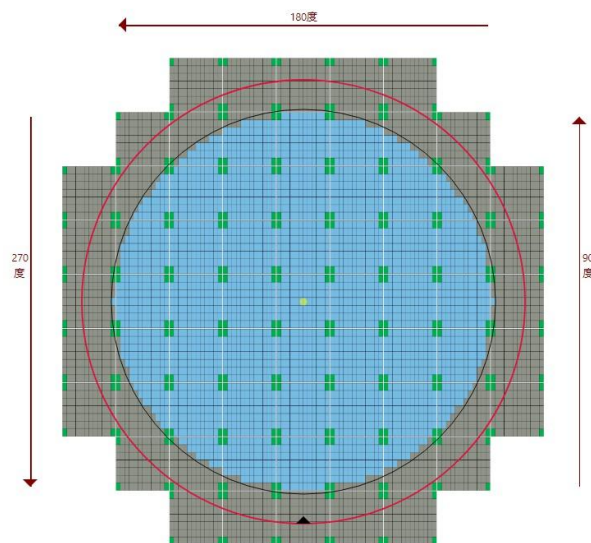
6 Wafer Information

* Shot Size		* Shot Die数量		Die Size	
* Width	18.126 mm	* X Die	12 颗	X Die	1.510500 mm
* Height	18.298 mm	* Y Die	7 颗	Y Die	2.614000 mm
Query PCM修改					

* 外围设定		* 圆心位移		* 平边位置	
* 缩进量	10 mm	* 横向	0 μm	* 大边	度
		* 纵向	0 μm	* 小边	度

* 平边尺寸		* Notch位置		预览	
* 大边	mm	* 0	度		
* 小边	mm				

绘图结果					
Gross Die数量:	3086	Die Pitch_X(μm):	1510.5	Die Pitch_Y(μm):	2614.0
PCM in Die:	148	Complete Shot:	29	Partial Shot:	32
导出 导出Map 保存					



7 Revision history

Major changes since the last revision

Revision	Date	Description of changes
1.0	2025-01-23	1.0 version release
2.0	2025-04-28	Implemented the Wafer Information
3.0	2025-05-23	Implemented Electrical Characteristic Diagram
4.0	2025-11-27	Update Electrical Characteristic data and Die Info